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(Use Several Sheets if Necessary)	Inventor NAIMARK, et al
	Group 2171 2165
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U.S. Patent Documents

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Examiner Initial	No.	Document No.	Publication Date	Country or Patent Office	Class	Sub-class	Translation	
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Examiner: Initial citation considered. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.